## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Atty. Docket

PAWLAK et al.

NL 031498

Serial No.

Group Art Unit

Filed: CONCURRENTLY

Ex.

A SEMICONDUCTOR SUBSTRATE WITH SOLID PHASE EPITAXIAL REGROWTH WITH REDUCED JUNCTION LEAKAGE AND METHOD OF PRODUCING SAME

Commissioner for Patents Alexandria, VA 22313-1450

## PRELIMINARY AMENDMENT

Sir:

Prior to calculation of the filing fee and examination, please amend the above-identified application as follows: